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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/604,891	08/25/2003	Takuji TANAKA	031032	1890
38834 7:	590 09/29/2005		EXAMINER	
WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP 1250 CONNECTICUT AVENUE, NW SUITE 700			LEE, EUGENE	
			ART UNIT	PAPER NUMBER
	N, DC 20036	2815	· •	

DATE MAILED: 09/29/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

		A/				
	Application No.	Applicant(s)				
Office Action Summan	10/604,891	TANAKA, TAKUJI				
Office Action Summary	Examiner	Art Unit				
The MAILING DATE of this communication on	Eugene Lee	2815				
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet with the	correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING D. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATION 136(a). In no event, however, may a reply be will apply and will expire SIX (6) MONTHS from the course the application to become ABANDO	ON. timely filed om the mailing date of this communication. NED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 30 A	August 2005.					
2a) ☐ This action is FINAL. 2b) ☒ This	☐ This action is FINAL. 2b) ☑ This action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under	Ex parte Quayle, 1935 C.D. 11,	453 O.G. 213.				
Disposition of Claims		·				
4) ⊠ Claim(s) 1,6-8 and 13-16 is/are pending in the 4a) Of the above claim(s) is/are withdra 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 1,6-8 and 13-16 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and/o	own from consideration.					
Application Papers						
9)☐ The specification is objected to by the Examina 10)☒ The drawing(s) filed on 25 August 2003 is/are: Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11)☐ The oath or declaration is objected to by the E	a) accepted or b) objecte drawing(s) be held in abeyance. Setion is required if the drawing(s) is a	See 37 CFR 1.85(a). objected to. See 37 CFR 1.121(d).				
Priority under 35 U.S.C. § 119						
a) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documen 2. Certified copies of the priority documen 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	ts have been received. ts have been received in Applica prity documents have been recei nu (PCT Rule 17.2(a)).	ation No ived in this National Stage				
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Paper No(s)/Mail Date	4) Interview Summa Paper No(s)/Mail 5) Notice of Informa 6) Other:					

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 8/30/05 has been entered.

Drawings

2. The drawings are objected to under 37 CFR 1.83(a). The drawings must show every feature of the invention specified in the claims. Therefore, (1) the notched shape (claim 6); and (2) said cavity formed to directly contact both sides of a lower portion of said gate (claim 13) must be shown or the feature(s) canceled from the claim(s). Regarding (1), FIGs. 3, and 4 show a notched shape, however, FIGs. 3, and 4 do not show a first film, and second film as disclosed in independent claim 1. Regarding (2), FIG. 2 shows a cavity 7 but it only contacts one side of a lower portion of said gate 3, not both sides. No new matter should be entered.

Corrected drawing sheets in compliance with 37 CFR 1.121(d) are required in reply to the Office action to avoid abandonment of the application. Any amended replacement drawing sheet should include all of the figures appearing on the immediate prior version of the sheet, even if only one figure is being amended. The figure or figure number of an amended drawing should not be labeled as "amended." If a drawing figure is to be canceled, the appropriate figure must be removed from the replacement sheet, and where necessary, the remaining figures must

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be renumbered and appropriate changes made to the brief description of the several views of the drawings for consistency. Additional replacement sheets may be necessary to show the renumbering of the remaining figures. Each drawing sheet submitted after the filing date of an application must be labeled in the top margin as either "Replacement Sheet" or "New Sheet" pursuant to 37 CFR 1.121(d). If the changes are not accepted by the examiner, the applicant will be notified and informed of any required corrective action in the next Office action. The objection to the drawings will not be held in abeyance.

Claim Rejections - 35 USC § 112

- 3. The following is a quotation of the second paragraph of 35 U.S.C. 112:
 - The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 4. Claim 13 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

It is unclear how a cavity formed can directly contact **both** sides of a lower portion of said gate. Appropriate clarification and/or correction are required.

Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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6. Insofar as definite, claims 1, and 13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kasai 5,821,594 in view of Wu 6,180,988 B1. Kasai discloses a semiconductor device comprising a gate oxide layer (gate insulation film) 53, gate electrode 54, n+- diffusion layer (source, drain) 58, silicon oxide layer (low permittivity region) 59, silicon oxide layer (first film) 55, and etch stop layer (second film) 56. Kasai does not disclose said low permittivity region being made of a lower permittivity material as compared to said sidewall film. However, Wu discloses (see, for example, FIG. 8) a semiconductor device comprising air gaps (low permittivity region) 22. In column 4, lines 26-27, Wu discloses the air gaps reduce the effect of gate fringe capacitance. Therefore, it would have been obvious to one of ordinary skill in the art at the time of invention to have said low permittivity region being made of a lower permittivity material as compared to said sidewall film in order to reduce the effect of gate fringe capacitance.

Regarding claim 13, see, for example, FIG. 4 wherein Kasai discloses an etch stop layer (third film) 56.

7. Claims 6 thru 8, and 14 thru 16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kasai '594 in view of Wu '988 B1 as applied to claims 1, and 13 above, and further in view of Lee 6,251,737 B1. Kasai in view of Wu does not disclose a part of a side wall lower portion of said gate is removed to have said low permittivity region formed into a notched shape. However, Lee discloses (see, for example, FIG. 1H) a MOS transistor comprising a gate polysilicon layer 116, and air spacers 136. The air spacers are formed in a notch underneath the gate polysilicon layer. In column 5, lines 60-66, Lee discloses that signal transmission delay is

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reduced, and the operating speed of the device is increased. Therefore it would have been obvious to one of ordinary skill in the art at the time of invention to have a part of a side wall lower portion of said gate is removed to have said low permittivity region formed into a notched shape in order to reduce signal transmission delay, and increase operating speed.

Response to Arguments

8. Applicant's arguments with respect to claims 1, 6-8, and 13-16 have been considered but are most in view of the new ground(s) of rejection.

INFORMATION ON HOW TO CONTACT THE USPTO

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eugene Lee whose telephone number is 571-272-1733. The examiner can normally be reached on M-F 8-5.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on 571-272-1664. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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Eugene Lee September 25, 2005

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